




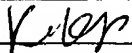
FORM PTO-1449 U.S. Department of Commerce Patent & Trademark Office	Attorney Docket No. 038788.52799US	Serial No. 10/670,744
	Applicant: Satoru KOBAYASHI, et al.	
	Filing Date: September 26, 2003	Group:

INFORMATION DISCLOSURE STATEMENT
(Use several sheets if necessary)

U.S. PATENT DOCUMENTS							
Examiner Initial		Document Number	Date	Name	Class	Sub-Class	Filing Date (if appropriate)
	AA						
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							Yes	No
	AK							
	AL							
	AM							
	AN							
	AO							
	AP							

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)		
	AQ	Kamon, et al., "Newly Developed Acrylic Copolymers for ArF Photoresist", <i>Journal of Photopolymer Science and Technology</i> , Vol. 15, No. 4 (2002), pp. 535-540
	AR	
	AS	

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